heavy-doped n-G aA s by using the tem perature resistance

dependence of m etal-sem iconductor contact

Therm om odulation studies of heat transport in

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Abstract. The heat transport in heavy-doped n-G aAs has been investigated at temperatures T = 300 K and 77 K using the irradiation of the metalsem iconductor contact by modulated CO $_2$ -laser radiation. It is shown this approach giving an opportunity to determ ine the therm o-di usion coe cient and Seebeck coe cient ST without direct m easurem ents of the tem perature gradient. It was also found out that the therm alization length of hot electrons exceeds in of order of m agnitude the assessment which can be done based on the reference data for G aAs. To elucidate the origin of the observed phenom enon the m easurem ents were conducted out with Schottky contacts m ade on the thin doped G aA s layer epitaxially grown on the sem i-insulating G aA s substrate. In this case the degenerate electron gas occupies only insigni cant part of the heat-conducting medium. In addition, the injection of hot electrons into the sem iconductor by current pulses through the Schottky barrier was used to clear up whether there is a dependence of the e ect on the method of the electron heating. The nonequilibrium of LO -phonons and the change in the electron-phonon collisional integral due to the non-equilibrium pair correlations of the electrons are suggested as a possible explanation.z

1. Experim ent and data handling

The frequency dependence of therm al response of the degenerate electron gas in G aAs (the Ferm ienergy 80 130 m eV) has been studied at spatially-nonuniform heating. The surplus energy of the electron gas was produced by free carriers absorption of chopped 10-m laser radiation (see Fig.1).

The opposite side of the sample was held at the equilibrium temperature. The change in the electron temperature T close to the metal-sem iconductor interface led to change in the m etal-sem iconductor tunnel junction resistance and to the nascent them oelectrom otive voltage. The plot in Fig.2 dem onstrates the dependence of the response V on the voltage bias V measured by phase-sensitive detector. At V = 0the response is the sole therm oelectrom otive signal. At V 6 0 the response is the sum of the therm o-em f. and the change in the V in the case of non-zero current I through the junction due to the tem perature dependence of the junction resistance R.

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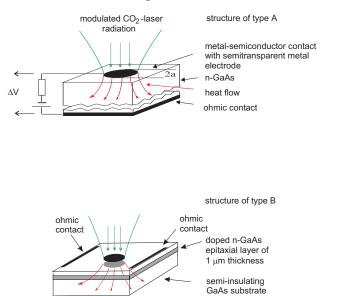
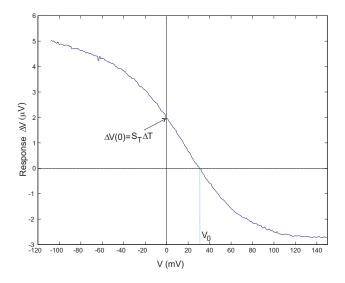


Figure 1. A draft of m easurem ent schem e and di erent types of sam ples' layout



F igure 2. B ias dependence of the therm oresponse to CO₂-laser radiation. The dependence of the response voltage $\,V\,$ on the chopper frequency F was the subject of the investigation. The bias voltage V_0 where the response changes in its sign can be used to determ ine the Seebeck coe cient S_T according to the Eq.(1). Experim ental parameters: electron density N = 7:0 $\,1b^8\,$ cm 3 , incident radiation power P = 250 mW, modulation frequency F = 570 Hz, environment tem perature T = 77 K.

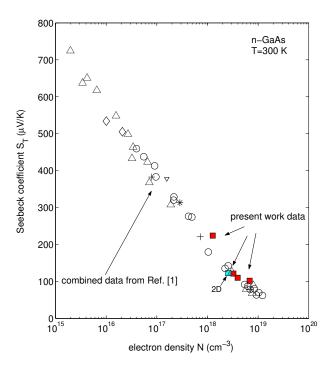
1.1. Bias dependence of therm or esponse and determ ination of Seebeck coe cient

Such an experimental setup allows us to suggest a simple way of measurement of the Seebeck coe cient S_T for the degenerate electron gas in the heavy-doped sem iconductor when the standard methods give a large spread of values (see e.g. [1]). A simple circuit small-signal analysis with the current-driven junction gives the condition for the bias V_0 where V = 0:

$$V \qquad V_0 \quad \frac{\partial \ln R}{\partial T} \quad S_T \quad T = 0:$$
 (1)

Here T is the temperature di erence averaged over the metal contact area. Evidently, it is possible to determ ine S_T from Eq.(1) without T measuring. All other quantities involved in this relation characterize the junction itself and can be easily measured. As an example, the value of $V_0 = 32 \text{ mV}$ presented in the Fig.1 being combined with the value of dln R=dT ' 10³ K¹ gives S_T ' 30 V/K in good agreement with the value expected for the indicated electron density and temperature. In fact, the derivation of Eq.(1) is based on the potentiality of the temperature- and C oulom b

elds and on the constancy of the C oulom b potential along all metal contacts including ohm ic ones [2]. This allows to prove the Eq.(1) is independent of geometry of the current and heat ows in the samples as long as the junction resistance is much greater than the bulk resistance of the substrate. Therefore, both type of the structures shown in Fig.1 have been suitable for that sort of measurements.



F igure 3. C om parative plot of electron density dependence of Seebeck coe cient in n-G aAs at T = 300 K. Selected by color data are obtained with the technique suggested in present work.

The Seebeck coe cients for several structures with various values of electron density m easured by this technique are presented in the Table and compared with known data in Fig.3.

preparation	structure	Ν,	$R_{\rm 300K}$,	$d \ln R = dT;$	V ₀ ;	S _T ;	T~ , K
technology	type	10 ¹⁸ cm ³	K O hm	10 ³ =K	m V	V/K	(F=600 Hz)
MOCVD	В	1.27	124.0	-6.49	34.4	-223	0,03
MBE	В	3.25	0.945	-17.8	6.8	-121	0 , 07
MBE	В	3.95	5.590	-11.1	9.93	-110	0,06
zone-m elting	A	6.80	0.004	-7.64	13.4	-102	0,11
MBE	В	2 . 60x	7.480	-6.38	192	-123	0,03

Table. Param eters of structures and respective Seebeck coe cients

1.2. M odulation frequency dependence of therm or sponse and determ ination of hot-electron therm alization length

The m easured frequency dependences of the therm or exponse for three junctions at two am bient tem peratures are shown in Fig.4 by m arkers. The curves 1–3 were m easured with the same junction m ade on the bulk-doped G aAs substrate. The curves 4 and 5 were m easured with the junctions m ade on the epitaxially-doped side of the sem i-insulating G aAs substrate. The thicknesses of the substrates varied in the 0.3 0.8 m m range. The thickness of the doped epi-layer of the sam ple for curve 4 w as about 1

m. The junction relating to the curve 5 was form ed by surface-deposited m et al lm and 2D electron gas in the -doped channel placed at the 20 nm distance from the sem iconductor surface.

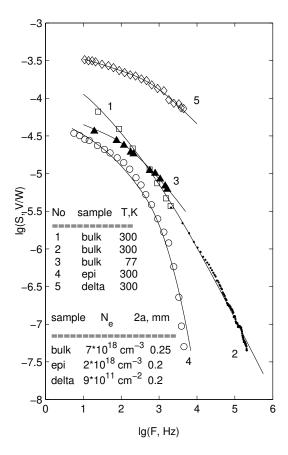
It is noticeably that curves 4 and 5 show more slow-down behavior than the curve 1 as a function of the modulation frequency F in the low-frequency region up to F 10^3 Hz. In fact, this dependence is closer to $1=F^{1=2}$ for the curve 4 and 5 and to 1=F for the curve 1. M ore quantitative comparison of the measured curves with the heat transport theory has been carried out on the base of the theoretical analysis presented in [4].

For the sake of simplicity of the discussion let us consider the corresponding expression for the response which takes into account all essential details of the measurements but the nite thickness of the substrate:

$$T() = \frac{P()(1 r)K}{a} \int_{0}^{2r} ds \frac{\exp(s^{2}b^{2}=2)J_{1}(sa)J_{0}(sd)}{i = +s^{2}} \int_{1}^{2r} ds \frac{1}{1 r} ds \frac{1}{1 r} \int_{0}^{2r} ds \frac{1}{1 r} \int_$$

Certainly, the real calculations have been conducted with the full more complicated formula. Here P() is the power of the incident radiation beam, = 2 F, r is the radiation relation coelection coelection, a is the radius of the metal contact, b is the dispersion of the G aussian distribution of the radiation power across the beam in the focal spot, d is the distance along the sample surface between the centre of the metal contact and the focal spot, is the sem iconductor heat conductivity and K is the free carrier absorption coep cient. In the case of heat transport in hom ogeneous medium the quantity $k = \frac{1}{1} = is$ the root of dispersion equation. At the real the Re 1=k plays the role of the wavelength and the Im 1=k is the attenuation length of the heat wave.

x Equivalent volume density of 2D electrons with N $_{\rm 2D}$ = 9 $\,10^{11}$ cm 2 in –doped layer of order of 3.5 nm width.



F igure 4. The dependence of the heating signals S on the frequency of CO₂-laser beam chopper for several tunnel Schottky-barrier junctions with various electron densities N_e and diam eters of the m etal contact 2a (curves 1, 3-5). Curve 2 was m easured using Q -sw itched CO₂ laser and the posterior Fourier-transform data processing. M arkers denote experim ental data. Solid curves have been calculated from Eq.(2) with param eters described in the text.

For the inhom ogeneous heating under consideration the frequency dependence of the right-hand side of Eq.(2) at d = 0 is determined an interrelation between $j_k j$ and rem inder of the scale parameters $a_j b_j K$. The case $d \in 0$ must be considered separately.

The qualitative analysis of the expression (2) as a function of with account for the actual limitation of the integration region by the damping exponential or oscillating Bessel function (or both) in the integrand shows that at factual values of parameters a and b of order 200 250 m and 1=K of order of 20 50 m the response must down as 1=F in the range of 10^2 Hz< F < 10^4 Hz and transforms s to 1=F law at higher frequencies. All these estimations are made at T = 300 K and reference value of the therm odi usion coe cient $_{300} = 0.26$ cm²/s obtained from therm occunductivity $_{300} = 0.46$ W cm⁻¹ K⁻¹ and heat capacity C₃₀₀ = 1:75 Jcm⁻³ K⁻¹ of G aAs given in [3] and [5]. Respective values for T = 77 K are $_{77} = 3.2$ W cm⁻¹ K⁻¹ ; C₇₇ = 0.85 Jcm⁻³ K⁻¹ ; $_{77} = 3.8$ cm²/s.

The observed behavior of the curve 1-3 in Fig.4 is evidently in contradiction with the reasoning presented above and exact computations of Eq.(2) support this evidence. Since the experimental data is represented in the form of amplitude of oscillating response, the thin theoretical curves in Fig.4 represents the absolute value of the Eq.(2). The tted solid curves show results of calculations with optim al values of the therm odi usivity coe cient and the reference values [, 3] of the radiation absorption coe cient K . 1-2: = $0.026 \text{ cm}^2/\text{s}$, K = 450 cm⁻¹, 3: = $0.38 \text{ cm}^2/\text{s}$, K = 450 cm⁻¹. The theoretical curves 4 and 5 were calculated at the reference values of = $0.26 \text{ cm}^2/\text{s}$ and K = 200 cm⁻¹. These results prove that the response of the samples where degenerate electron gas occupies only small part of the substrate volume can be described with the standard value of the therm odi usivity . O therwise (curves 1-3), the values of were needed to decrease in 10 times. The very sharp drop of the curve 4 in the high-frequency tail is the result of large displacem ent (250 m) between the centers of the focused laser beam (b = 45 m) and the metal electrode. Such a kind of measurem ents allows to determ ine directly disregarding uncertainties of other param eters involved as it will farther be explained.

By inspecting of Fig.4 one can see that exact calculations of Eq.(2) with the indicated reference values of the parameters and K enable to describe the measured frequency dependence for the junctions on the epitaxially-grown substrates only (curves 4 and 5). Just in this case the heat transport passes mainly through the part of the sem iconductor substrate that is free of electrons. In the other case, presented by curves 1–3, the used values of were reduced in 10 times to reach an agreement with experimental data under all measurement conditions. A lm ost the same results can be obtained with the reference values of and reduced in 10 times K. The meaning of this interchangeability will be discussed later. It follows that just the electronic constituent is responsible for the anom alous heat propagation in the sem iconductor.

To check if the observed e ect depends on the way of the electron heating, the pulsed current heating at the reverse- and the forward polarities was realized by specially designed switching electronic circuit. The circuit enabled to measure the therm or sponse signal of order of 200 nV in 50 100 s after the voltage pulse of 1 V m agnitude was supplied, in spite of the large capacitance 2 5 nF of the investigated junctions. The time-dependent pulsed response measured by the boxcar integrator was converted them in the frequency dom ain using digital Fourier transform ation.

It turn out that frequency dependences obtained at the reverse and forward pulsed bias are di erent. At the forward bias the non-equilibrium electrons were generated inside them etal Im and the emitted phonons only were primary mechanism for the heat transport into the semiconductor. In that case, the calculated frequency dependence of the response manifested _ 1=F¹⁼² drop-down behavior up to several hundred kHz corresponding to the near-surface heat generation and the normally expected lattice heat transport into the semiconductor. At the reverse bias electrons were injected across the Schottky barrier from the metal electrode into the semiconductor with kinetic energy about 1 eV above Fem i level and produced highly non-equilibrium state of the electron gas due to intensive electron-electron collisions. That is the Joule heat was directly scattered inside the electron gas of the sem iconductor. The respective frequency dependence shows the main sign of the abnormal heat transport, e.g., the fall o more sharp then $1=F^{1=2}$ beginning from several hundred Hz.

In principle, the therm or esponse can fall o $\$ with the frequency more quickly then 1=F even under the norm all heat transport conditions as it is seen from the

experimental and calculated curves 4 in Fig.4. That case takes place for $d \in 0$, i.e., when there is a distance between the centers of the metal electrode and the focal spot. Surely, this behavior is contained in the Eq.(2) and can be explained on that ground. However, there is a simpler way to understanding that gives us also some practically useful means. The solution of the heat conductivity equation far away the excitation region has the asymptotic form like exp (ik d)=d. Taking into account the dennition of k given above it is easy to obtain the dependence of the response S on the frequency

at d constant in the form

$$\ln S _ d =2 :$$
(3)

A coordingly to this expression there is the linear dependence of $\ln S$ on ¹⁼². That dependence can be applied to the determ ination of without any reference to the junction (heat detector) characteristics and irradiation conditions excluding the distance d. The application of the claim ed m ethod to the curve 4 results in the value of 0.23 cm²/s in a good agreem ent with the adopted value 0.26 cm²/s.

2. D iscussion

The observed anom alous frequency dependence of the therm al response can be related either to a diminution of an e ective them ald i usivity in the system of electrons + LO -phonons + acoustic phonons or to a real increasing of the size of the region where the therm alization of the nonequilibrium electron -LO -phonon subsystem takes place ow ing to the interaction with the therm albath of acoustic phonons. The investigated frequency band of the heating modulation is too low-frequency for one to expect dim inution of the thermaldi usivity owing to the mechanism examined in §]. The change in = = C may be attributed either change in or in C or in both. Since the heat conductivity appears in Eq.(2) in front of the integral besides we can use the absolute m agnitude of the response to distinguish the contributions of and C in the observed change of therm odi usivity . The realization of this procedure shown that the main role in the change of belong to the heat capacitance, if this change does exist. The joint set of heat conductivity equations for the electrons, LO -phonons, and acoustic phonons analyzed in [4] allows supposing that the st case might be considered as the result from rising the contribution of the nonequilibrium electron -LO -phonon subsystem to the heat capacity of the sem iconductor.

The second case may be taken into consideration because the calculated curves consist also with the measured data 1-3 for the bulk-doped sample in Fig.4 at thermodi usivity $_{300} = 0.26 \text{ cm}^2/\text{s}$ and $_{77} = 3.8 \text{ cm}^2/\text{s}$ (reference values) and reduced radiation absorption coe cient K = 50 cm⁻¹ instead of K = 500 cm⁻¹. The value = $0.26 \text{ cm}^2/\text{s}$ has been con-med by direct measurements of the therm oresponse as a function of the intercenter distance d according to Eq.(3). The observed phenomenon can then be interpreted as a long-range taile ect in the spatial response of an inhom ogeneous electron gas corresponding to the known long-time tail in the time response of spatially-hom ogeneous electron gas. A s it is known, the latter is related with the nonequilibrium corrections to the pair correlation function of electrons. In [7] the expression for the electron energy loss rate via electron-phonon interaction was derived with explicitly found contribution of the nonequilibrium pair correlations. However, the role of this correction in the heat transport is unclear yet.

A cknow ledgm ents

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